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Feasibility study of atmospheric-pressure dielectric barrier discharge treatment on $CH_3NH_3PbI_3$ films for inverted planar perovskite solar cells

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PII: S0013-4686(18)32213-8

DOI: 10.1016/j.electacta.2018.09.203

Reference: EA 32794

To appear in: Electrochimica Acta

Received Date: 27 May 2018

Accepted Date: 30 September 2018

Please cite this article as: Jui-Hsuan Tsai, I-Chun Cheng, Cheng-Che Hsu, Chu-Chen Chueh, Jian-Zhang Chen, Feasibility study of atmospheric-pressure dielectric barrier discharge treatment on CH $_3$ NH $_3$ Pbl $_3$ films for inverted planar perovskite solar cells, *Electrochimica Acta* (2018), doi: 10.1016/j. electacta.2018.09.203

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ACCEPTED MANUSCRIPT

Feasibility study of atmospheric-pressure dielectric barrier discharge treatment on CH₃NH₃PbI₃ films for inverted planar perovskite solar cells

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Abstract

A facile surface treatment of the CH₃NH₃PbI₃ film is conducted using a portable

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